	Hits	Search Text	DBs
50	12	resist or photosensitive or imag\$3 or photoimag\$5) same (diffus\$5 or infus\$5 or proton) same (cohemical\$5 near9 amolif\$4	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

(((protective near12 (layer or coat\$3)) or ((top or overlying) near5 (coat\$4 or layer)) or (ARC near26 diffus\$4) or (protective near26 diffus\$4)) same (photoresist or resist or photosensitive or imag\$3 or photoimag\$5) same (diffus\$5 or infus\$5 or permeat\$5) same (acid or proton) same ((chemical\$5 near9 amplif\$4 near5 resist) or PAG or (photoacid near5 51 US-PGPUB generat\$4) or (acid near6 (diffus\$4 or generat\$4 or liberat\$4))) same (heat\$4 or post\$4bak\$4 or post\$4heat\$4 or harden\$5)) and (((remov\$4 or solubiliz\$3 or soluble) near22 (expos\$4 near9 (region or portion or pattern or area))) same (polarity or charg\$3) same (photoresist or resist) same (top\$3coat\$4 or ARC or TARC or protective))

Н	lits	Search Text	DBs
52 6		near9 amplif\$4 near5 resist) or PAG or (photoacid near5 generat\$4) or (acid near6 (diffus\$4 or generat\$4 or	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
53	0	or proton) same ((chemical\$5 near9 amplif\$4 near5 resist) or PAG or (photoacid near5 generat\$4) or (acid near6	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_IDB

	Hits	Search Text	DBs
54	0	near9 amplif\$4 near5 resist) or PAG or (photoacid near5 generat\$4) or (acid near6	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB